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(71) Applicant: SOLVAY SA [BE/BE]; Rue de Ransbeek,
310, B-1120 Bruxelles (BE).

(72) Inventors: EICHER, Johannes; Ratswinkel 6, 31319
Sehnde (DE). PERNICE, Holger; Heilshorner Strasse
36B, 28790 Schwanewede (DE). LACROIX, Marc; 29
rue du Bassinia, B-1348 Louvain-la-neuve (BE).
SCHWARZE, Thomas; Planetenstrasse 80, 31275 Ahlten
(DE). HASENSTAB-RIEDEL, Sebastian; Ernst-Thäl-
mann Strasse 84, 14532 Kleinmachnow (DE).

(74) Agents: MROSS, Stefan et al.; Rue de Ransbeek, 310, B-
1120 Bruxelles (BE).

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(54) Title: A METHOD FOR DIELECTRICALLY INSULATING ACTIVE ELECTRIC PARTS

(57) Abstract: A method for dielectrically insulating active electric parts A method for dielectrically insulating an active electric part wherein the electrical active part is arranged in a gas-tight housing comprising an insulating gas which contains or consists of a compound of formula (i) $Rf_1-(O)_x-Rf_2$ wherein Rf_1 and Rf_2 are identical or different and designated fluorocarbon residues having a H/F ratio of equal to or less than 0.5 and x is 1, 2, or 3.



WO 2014/096414 A1

A method for dielectrically insulating active electric parts

This application claims priority to European application 12199091.5 filed on 21 Dec 2012, the whole content of this application being incorporated herein by reference for all purposes.

The invention concerns a method for dielectrically insulating active electric parts a dielectric insulation medium comprising certain oxygenated fluorocompounds, certain such compounds per se and the use of such compounds as a component in a dielectric insulating medium.

Dielectric insulation media in liquid or gaseous state are applied for the insulation of electrical active parts in a wide variety of electrical apparatuses, e.g. in switchgears or transformers.

Mixtures of SF₆ and N₂ are widely applied as dielectric insulating gas. Efforts have been made in the past to provide alternative dielectric insulating gases.

US-A-2008/0135817 relates to the problem of SF₆ substitution. While it mentions CF₃-O-O-CF₃ as a speculative substitute in a long very diverse list of other compounds, no specific technical information concerning its use is given and working examples only relate to use of certain hydrofluoroalkanes or of SiF₄.

The object of the present invention is to provide an improved for electrical insulation of electrical active parts. This object and other objects are achieved by the current invention.

The method of the present invention provides for a method for dielectrically insulating an active electric part wherein the electrical active part is arranged in a gas-tight housing comprising an insulating gas which contains or consists of a compound of formula



wherein Rf1 and Rf2 are identical or different and designated fluorocarbon residues having a H/F ratio of equal to or less than 0.5 and x is 1, 2, or 3 and wherein the content of compound of formula (I) in the insulating gas is preferably equal to or greater than 1 % by volume relative to the volume of the insulating gas.

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Compounds of formula (I)^o can be manufactured for example by reaction of a fluorinated hypofluorite, such as CF₃OF with COF₂, for example as described in US-A-2007/0049774. Compounds of formula (I) with x=3 can be manufactured, for example, as described in Angew. Chem. Int. Ed.

5 English 34(20), p.2244-5.

Generally, in the method according to the invention, compounds wherein Rf1 and Rf2 contain independently from 1 to 3 carbon atoms can be suitably used.

10 In the method according to the invention, the compound of formula (I) has an generally an atmospheric boiling point of less than 20°C, preferably equal to or lower than 0°C preferably equal to or less than -10°C. In the method of according to the invention, the compound of formula (I) has an generally an atmospheric boiling point of equal to or higher than -80°C, preferably equal to or higher than -50°C.

15 In a preferred aspect of the method according to the invention the compound of formula (I) is perfluorinated. In this case, Rf1 and Rf2 are often independently selected from methyl, ethyl, n-propyl and isopropyl. Preferred compounds of formula (I) are selected from CF₃-O-CF₃, CF₃-O-O-CF₃ and CF₃-O-O-O-CF₃, CF₃-O-O-CF₃ is more particularly preferred.

20 In another aspect of the method according to the invention the compound of formula (I) is not perfluorinated. In this case, Rf1 and Rf2 are often independently selected from difluoromethyl, tetrafluoroethyl, n-hexafluoropropyl and isohexafluoropropyl, preferably difluoromethyl.

The term "electrical active part" has to be understood very broadly.
25 Preferably, it covers any part which is used for the generation, the distribution or the usage of electrical energy provided it comprises a gas-tight housing wherein the dielectric insulating gas provides for the dielectric insulation of parts which bear voltage or current. Preferably, the electrical active parts are medium voltage or high voltage parts. The term "medium voltage" relates to a voltage in
30 the range of 1 kV to 72 kV ; the term "high voltage" refers to a voltage of more than 72 kV. While these are preferred electrical active parts in the frame of the present invention, the parts may also e low voltage parts with a voltage below 1 kV being concerned.

35 In the frame of the present invention, the singular is intended to include the plural, and vice versa.

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It has to be noted that the electrical active parts of the invention can be “stand alone” parts, or they can be part of an assembly of parts, e.g. of an apparatus. This will now be explained in detail.

5 The electrical active part can be a switch, for example, a fast acting earthing switch, a disconnecter, a load-break switch or a puffer circuit breaker, in particular a medium-voltage circuit breaker (GIS-MV), a generator circuit breaker (GIS-HV), a high voltage circuit breaker, a bus bar a bushing, a gas-insulated cable, a gas-insulated transmission line, a cable joint, a current transformer, a voltage transformer or a surge arrester.

10 The electrical active part may also be part of an electrical rotating machine, a generator, a motor, a drive, a semiconducting device, a computing machine, a power electronics device or high frequency parts, for example, antennas or ignition coils.

15 The method of the invention is especially suited for medium voltage switchgears and high voltage switchgears.

In the electrical active part, the insulating gas is preferably at a pressure of equal to or greater than 0.1 bar (abs.). The insulating gas is at preferably a pressure equal to or lowers than 30 bar (abs). A preferred pressure range is from 1 to 20 bar (abs.).

20 The partial pressure of compound of formula (I) depends, i.a., upon its concentration in the isolating gas. If the dielectric isolating gas consists of compound of formula (I), its partial pressure is equal to the total pressure and corresponds to the ranges given above. If the dielectric gas includes an inert gas, the partial pressure of compound of formula (I) is correspondingly lower. A
25 partial pressure of compound of formula (I) which is equal to or lower than 10 bar (abs) is preferred.

In a preferred embodiment, the insulating gas comprises compound of formula (I) and an inert gas. The term “inert gas” denotes a gas which is non-reactive under the conditions in the electrical active parts. For example, any
30 other dielectric insulating gas may be applied as “inert gas” additionally to the content of compound of formula (I).

It is preferred that the composition of the dielectric insulating gas and especially that the content of compound of formula (I) in the inert gas is such that under the climate conditions or the temperature in the ambience of the
35 electrical apparatus, under the pressure in the electrical part, essentially no condensation of the components in the dielectric insulating gas occurs. The term

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”essentially no condensation” denotes that at most 5 % by weight, preferably at most 2 % by weight, of the dielectric insulating gas condenses. For example, the amounts of compound of formula (I) the kind and amount of inert gas are selected such that the partial pressure of compound of formula (I) is lower than the pressure where condensation of compound of formula (I) is observed at -20°C.

In another preferred embodiment, the insulating gas comprises compound of formula (I) and air or synthetic air.

In the insulating gas, the content of compound of formula (I) is preferably equal to or greater than 1 % by volume. In the insulating gas, the content of compound of formula (I) is preferably equal to or lower than 30 % by volume. In a particular embodiment the insulating gas further comprises SF₆, preferably in an amount from 0.5 % to 20 % by volume, more preferably 1 % to 10 % by volume relative to the volume of the insulating gas.

In the different embodiments described here before the balance to 100 % by volume can be inert gas. In another aspect of the different embodiments described here before, the balance to 100 % by volume is air or synthetic air.

Most preferably, the content of compound of formula (I) in the dielectric insulating gas is from 5 to 25 % by volume. Preferably, the inert gas is selected from the group consisting of nitrogen and helium. Nitrogen as inert gas is especially preferred, and the insulating gas of the present invention consists essentially of compound of formula (I), optionally SF₆ and nitrogen.

Another object of the invention concerns a gas mixture, as herein described, comprising a compound of formula

$$\text{Rf1-(O)}_x\text{-Rf2} \quad (\text{I})$$

wherein Rf1 and Rf2 are identical or different and designated fluorocarbon residues having a H/F ratio of equal to or less than 0.5 and x is 1, 2, or 3 and an air or an inert gas, preferably argon, helium or nitrogen, more preferably nitrogen.

Still another object of the invention concerns a gas mixture, as herein, described, comprising a compound of formula

$$\text{Rf1-(O)}_x\text{-Rf2} \quad (\text{I})$$

wherein Rf1 and Rf2 are identical or different and designated fluorocarbon residues having a H/F ratio of equal to or less than 0.5 and x is 1, 2, or 3, SF₆ and an inert gas or air.

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Another object of the present invention concerns the use of compound of formula (I) or of the gas mixtures according to the invention, as herein described, as dielectric insulating gas or as constituent of a dielectric insulating gas.

Should the disclosure of any patents, patent applications, and publications
5 which are incorporated herein by reference conflict with the description of the present application to the extent that it may render a term unclear, the present description shall take precedence.

The following examples further explain the invention without intention to limit it.

10 Example 1 : Manufacture of $\text{CF}_3\text{-O-O- CF}_3$

$\text{CF}_3\text{-O-O- CF}_3$ is manufactured as described in Example 3 of US-A-2007/0049774.

Example 2 : Manufacture of dielectric insulating gases

As described in WO98/23363, a homogenous mixture consisting
15 of $\text{CF}_3\text{-O-O- CF}_3$ and N_2 in a volume ratio 1:4 is manufactured in an apparatus comprising a static mixer and a compressor.

Example 3 : Provision of an earth cable containing the dielectric insulating gas of example 2

The gas mixture of example 2 is directly fed into an earth cable for high
20 voltage, until a total pressure of 10 bar (abs) in the cable is achieved.

Example 4 : A switchgear containing $\text{CF}_3\text{-O-O- CF}_3$ and N_2 in a volume ratio 1:4

A switchgear is used which contains a switch surrounded by a gas tight metal case. The gas mixture of example 2 is passed into the gas tight metal case via a valve until a pressure of 18 bar (abs) is achieved.

25 Example 5 : Provision of a gas-insulated transmission line containing the dielectric insulating gas of example 3

The gas mixture of example 2 is directly fed into an earth cable for high voltage, until a total pressure of 10 bar (abs) in the cable is achieved.

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CLAIMS

1. A method for dielectrically insulating an active electric part wherein the electrical active part is arranged in a gas-tight housing comprising an insulating gas which contains or consists of a compound of formula

5 $Rf1-(O)_x-Rf2$ (I)

wherein Rf1 and Rf2 are identical or different and designated fluorocarbon residues having a H/F ratio of equal to or less than 0.5 and x is 1, 2, or 3 and wherein the content of compound of formula (I) in the insulating gas is preferably equal to or greater than 1 % by volume relative to the volume of the
10 insulating gas.

2. The method of claim 1 wherein the compound of formula (I) is perfluorinated.

3. The method of claim 1 or 2 wherein Rf1 and Rf2 contain independently from 1 to 3 carbon atoms.

15 4. The method of anyone of claims 1 to 3 wherein the compound of formula (I) has an atmospheric boiling point of less than 20°C, preferably equal to or lower than 0°C.

5. The method of anyone of claims 1 to 4 wherein the compound of formula (I) is selected from CF₃-O-CF₃, CF₃-O-O-CF₃ and CF₃-O-O-O-CF₃.

20 6. The method of any one of claims 1 to 5 wherein the insulating gas comprises the compound of formula (I) and an inert gas.

7. The method of claim 6 wherein the inert gas is selected from the group consisting of nitrogen, argon and helium, preferably nitrogen.

25 8. The method of any of claims 1 to 5 wherein the insulating gas comprises the compound of formula (I) and air or synthetic air.

9. The method of any one of claims 1 to 8 wherein the content of compound of formula (I) in the insulating gas is from > 1 to 80 % by volume, preferably from 5 to 25 % by volume.

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10. The method of anyone of claims 1 to 9 wherein the insulating gas further comprises SF₆, preferably in an amount from 0.5 % to 20 % by volume, more preferably 1 % to 10 % by volume relative to the volume of the insulating gas.

5 11. The method of anyone of claims 1 to 10 wherein the insulating gas is at a pressure from equal to or greater than 0.1 bar (abs.) to equal to or lower than 30 bar (abs).

12. The method of any one of claims 1 to 11 wherein the electrical active parts are electrical apparatuses or are parts of an electrical apparatus which is
10 selected from the group consisting of medium and high voltage apparatus.

13. Gas mixture comprising a compound of formula



wherein Rf1 and Rf2 are identical or different and designated fluorocarbon residues having a H/F ratio of equal to or less than 0.5 and x is 1, 2, or 3 and an
15 inert gas or air.

14. Gas mixture comprising a compound of formula



wherein Rf1 and Rf2 are identical or different and designated fluorocarbon residues having a H/F ratio of equal to or less than 0.5 and x is 1, 2, or 3, SF₆
20 and an inert gas or air.

15. Use of a compound of formula (I) in accordance with anyone of claims 1 to 5 or of the gas mixtures according to claims 13 or 14, as dielectric insulating gas or as constituent of a dielectric insulating gas.

INTERNATIONAL SEARCH REPORT

International application No

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A. CLASSIFICATION OF SUBJECT MATTER
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ADD.

According to International Patent Classification (IPC) or to both national classification and IPC

B. FIELDS SEARCHED

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H01B

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Electronic data base consulted during the international search (name of data base and, where practicable, search terms used)

EPO-Internal, WPI Data

C. DOCUMENTS CONSIDERED TO BE RELEVANT

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
X	US 2008/135817 A1 (LULY MATTHEW H [US] ET AL) 12 June 2008 (2008-06-12) claims 2,3,5,7,8,10,11 -----	1-15
X	WO 2012/080222 A1 (ABB RESEARCH LTD [CH]; MAHDIZADEH NAVID [CH]; PAUL THOMAS ALFRED [CH];) 21 June 2012 (2012-06-21) claims -----	1-15
X	US 4 296 003 A (HARROLD RONALD T ET AL) 20 October 1981 (1981-10-20) column 2, line 14; claim 12; figure 1 -----	1-15
X	US 5 605 882 A (KLUG DIANA L [US] ET AL) 25 February 1997 (1997-02-25) claims -----	13



Further documents are listed in the continuation of Box C.



See patent family annex.

* Special categories of cited documents :

"A" document defining the general state of the art which is not considered to be of particular relevance

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"Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art

"&" document member of the same patent family

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European Patent Office, P.B. 5818 Patentlaan 2
NL - 2280 HV Rijswijk
Tel. (+31-70) 340-2040,
Fax: (+31-70) 340-3016

Authorized officer

Zeslawski, Wojciech

INTERNATIONAL SEARCH REPORT

Information on patent family members

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